





UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov APPLICATION NO. FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO CONFIRMATION NO. 11/08/2001 TI-23546 7628 10/007,839 Theodore W. Houston 05/22/2002 23494 7590 TEXAS INSTRUMENTS INCORPORATED EXAMINER P O BOX 655474, M/S 3999 SCHILLINGER, LAURA M DALLAS, TX 75265 PAPER NUMBER ART UNIT 2813 DATE MAILED: 05/22/2002

Please find below and/or attached an Office communication concerning this application or proceeding.

	Q .	_	-	A	
		Application No.	Applicant(s)		
	Office Action Summary	10/007,839	HOUSTON ET AL.		
•		Examiner	Art Unit	-	
		Laura M Schillinger	2813		
Period fo	The MAILING DATE of this communication app	pears on the cover sheet w	vith the correspondence addres	S	
A SH THE I - Exte after - If the - Failu - Any	ORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a repl period for reply is specified above, the maximum statutory period are to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a ly within the statutory minimum of th will apply and will expire SIX (6) MO e, cause the application to become A g date of this communication, even it	reply be timely filed rty (30) days will be considered timely. NTHS from the mailing date of this commu. BANDONED (35 U.S.C. § 133).	nication.	
1)⊠	Responsive to communication(s) filed on <u>08 i</u>	November 2001 .			
2a) <u></u> □	This action is FINAL . 2b)⊠ This action is non-final.				
3) <u></u>	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.				
•	ion of Claims	~			
	Claim(s) <u>1-11</u> is/are pending in the application 4a) Of the above claim(s) is/are withdra				
	Claim(s) is/are allowed.	wit from consideration.			
5)					
	Claim(s) <u>1-11</u> is/are rejected.				
7) 📙	Claim(s) is/are objected to.				
	Claim(s) are subject to restriction and/c ion Papers	or election requirement.			
	The specification is objected to by the Examine	er			
—	D) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.				
. •/	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).				
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.					
If approved, corrected drawings are required in reply to this Office action.					
12)	The oath or declaration is objected to by the Ex	xaminer.			
Priority (under 35 U.S.C. §§ 119 and 120				
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).					
a)	☐ AİI b)☐ Some * c)☐ None of:				
	1. Certified copies of the priority documen	ts have been received.			
	2. Certified copies of the priority documen	ts have been received in	Application No		
* (Copies of the certified copies of the price application from the International Bussee the attached detailed Office action for a list.	ureau (PCT Rule 17.2(a))		ge	
[°] 14)∏ /	Acknowledgment is made of a claim for domest	tic priority under 35 U.S.C	c. § 119(e) (to a provisional app	olication).	
	a) The translation of the foreign language pr Acknowledgment is made of a claim for domes				
Attachmer					
2) Noti	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948) rmation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of	w Summary (PTO-413) Paper No(s) of Informal Patent Application (PTO-15		



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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-11 are rejected under 35 U.S.C. 102(b) as being anticipated by Blewer et al ('200).

In reference to claim 1, Blewer teaches a method comprising:

- a) forming a structure (Fig.4 (5)) having porous semiconductor material at a first surface thereof (Fig.4 (4));
- b) introducing an oxidizing species into the porous semiconductor material; and either before or after step b).
- c) forming an epitaxial semiconductor layer on the porous material (Col.2, lines: 5-10), and reacting the oxidizing species with the porous semiconductor material to form a buried dielectric layer beneath the epitaxial layer (Col.2, lines: 10-20).

In reference to claim 2, Blewer teaches wherein the oxidizing species consists of O (col.2, lines: 10-20).



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In reference to claim 3, Blewer teaches wherein the semiconductor layer consists of Si (Col.2, lines: 10-15).

In reference to claim 4, Blewer teaches a method comprising:

- a) anodizing a Si wafer to form porous Si (Col.3, lines: 50-55 and Col.2, lines: 30-45);
- b) introducing O into the porous Si and either before or after step b) (Col.2, lines: 10-20);
- c) forming a semiconductor layer on the porous Si and reacting the O with the porous semiconductor material to form a BOX (Col.2, lines: 1-20).

In reference to claim 5, Blewer teaches wherein the semiconductor layer consists of Si (Col.2, lines: 10-15).

In reference to claim 6, Blewer teaches a method comprising:

- a) partially anodizing a Si wafer to form porous Si (Col.3, lines: 30-40);
- . b) forming an epi layer on the porous Si (Col.2, lines: 5-20)
- b) introducing O into the porous Si reacting the O with the porous semiconductor material to form a BOX (Col.2, lines: 5-20).

In reference to claim 7, Blewer teaches wherein the oxidizing species consists of O (Col.2, lines: 10-20).



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In reference to claim 8, Blewer teaches wherein the semiconductor layer consists of Si(Col.2,

lines: 10-15).

In reference to claim 9, Blewer teaches the device as a result of claim 1 (linking claimautomatically rejected with claim 1).

In reference to claim 10, Blewer teaches the device as a result of claim 4 (linking claim-automatically rejected with claim 4).

In reference to claim 11, Blewer teaches the device as a result of claim 6 (linking claimautomatically rejected with claim 6).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Laura M Schillinger whose telephone number is (703) 308-6425. The examiner can normally be reached on M-F 7:00 -4:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on (703) 306-2794. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 308-7722 for regular communications and (703) 308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-1500.



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LMS May 13, 2002

> OLIK CHAUDHURI SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800